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Correction: Stable DNA-based reaction–diffusion patterns

John Zenk,^a Dominic Scalise,^a Kaiyuan Wang,^a Phillip Dorsey,^a Joshua Fern,^a Ariana Cruz^a and Rebecca Schulman^{*ab}

Correction for 'Stable DNA-based reaction–diffusion patterns' by John Zenk *et al.*, *RSC Adv.*, 2017, 7, 18032–18040.

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The Royal Society of Chemistry apologises for these errors and any consequent inconvenience to authors and readers.

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^aChemical and Biomolecular Engineering, Johns Hopkins University, Baltimore, Maryland 21218, USA. E-mail: rschulm3@jhu.edu

^bComputer Science, Johns Hopkins University, Baltimore, Maryland 21218, USA

